

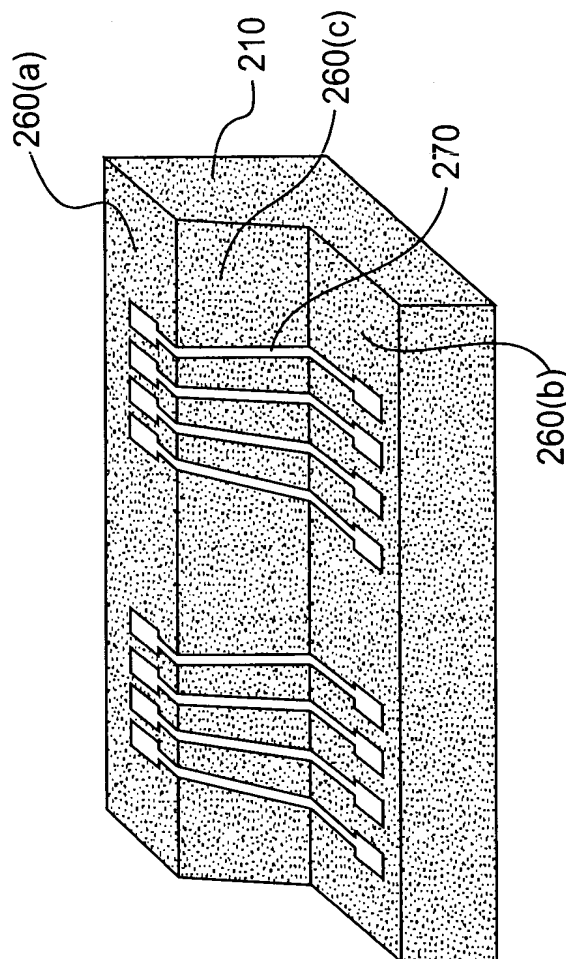
**FIG. 1**  
**PRIOR ART**

**Title:** METHOD AND APPARATUS FOR USING AN EXCIMER LASER TO PATTERN  
ELETRODEPOSITED PHOTORESIST

**Inventor(s):** Laurie S. MITTELSTAEDT

**Contact Name:** Susan E. Heminger (650) 236-2738

**Attorney Docket No.:** 10007343



**FIG. 2**

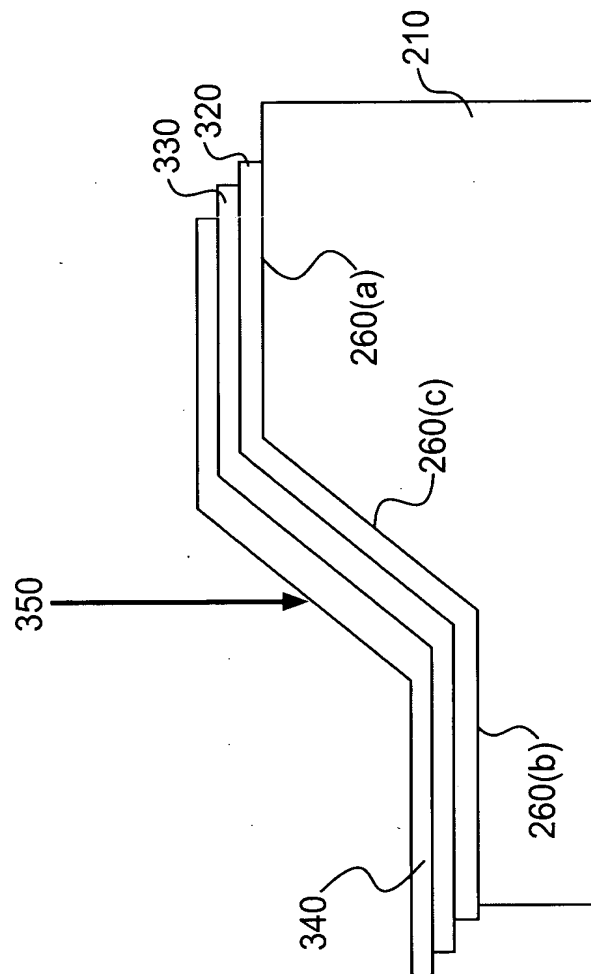


FIG. 3

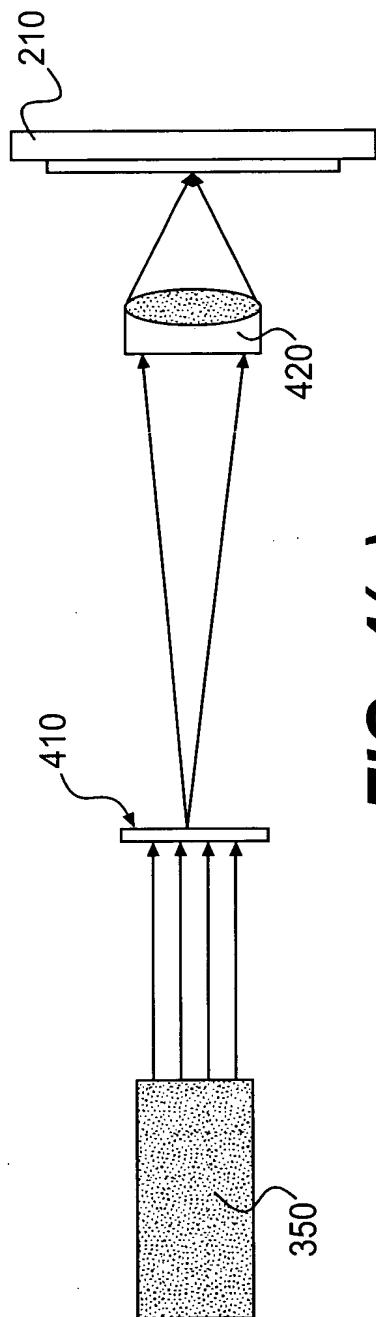


FIG. 4(a)

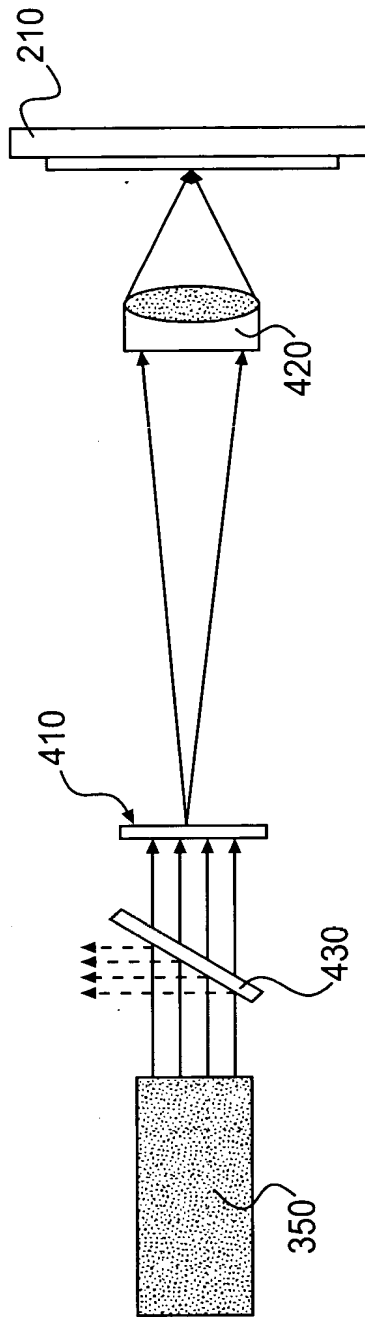


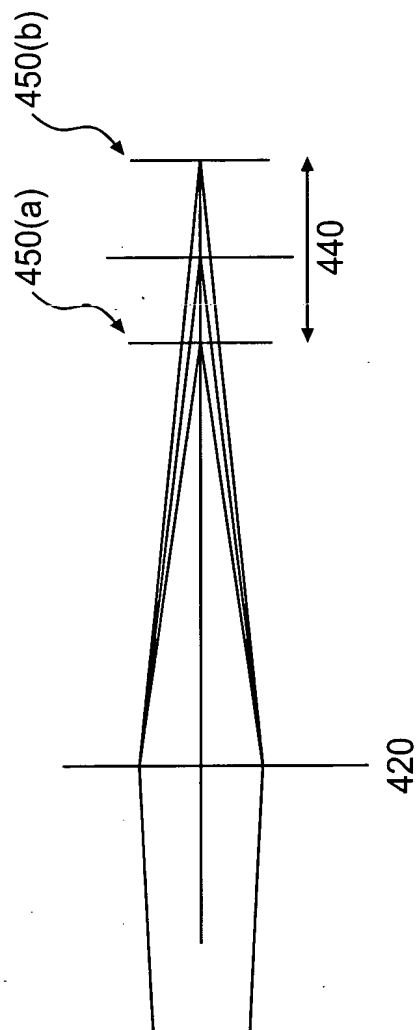
FIG. 4(b)

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**FIG. 4(c)**

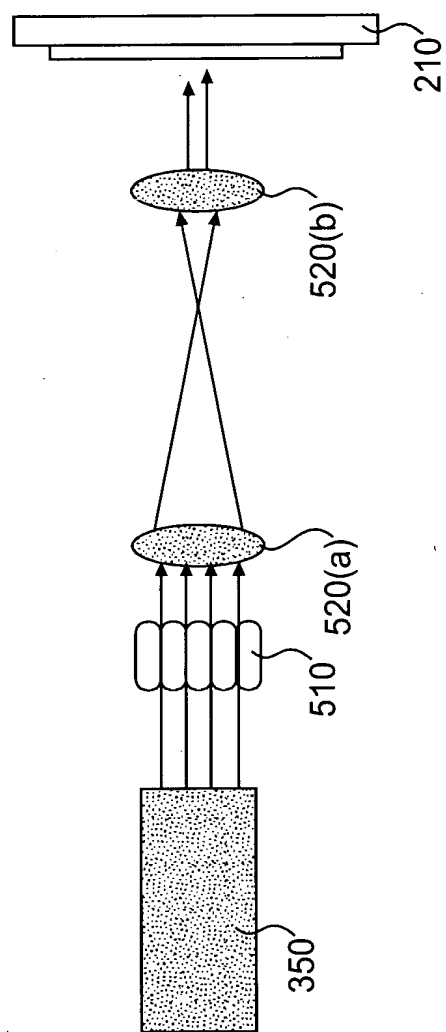
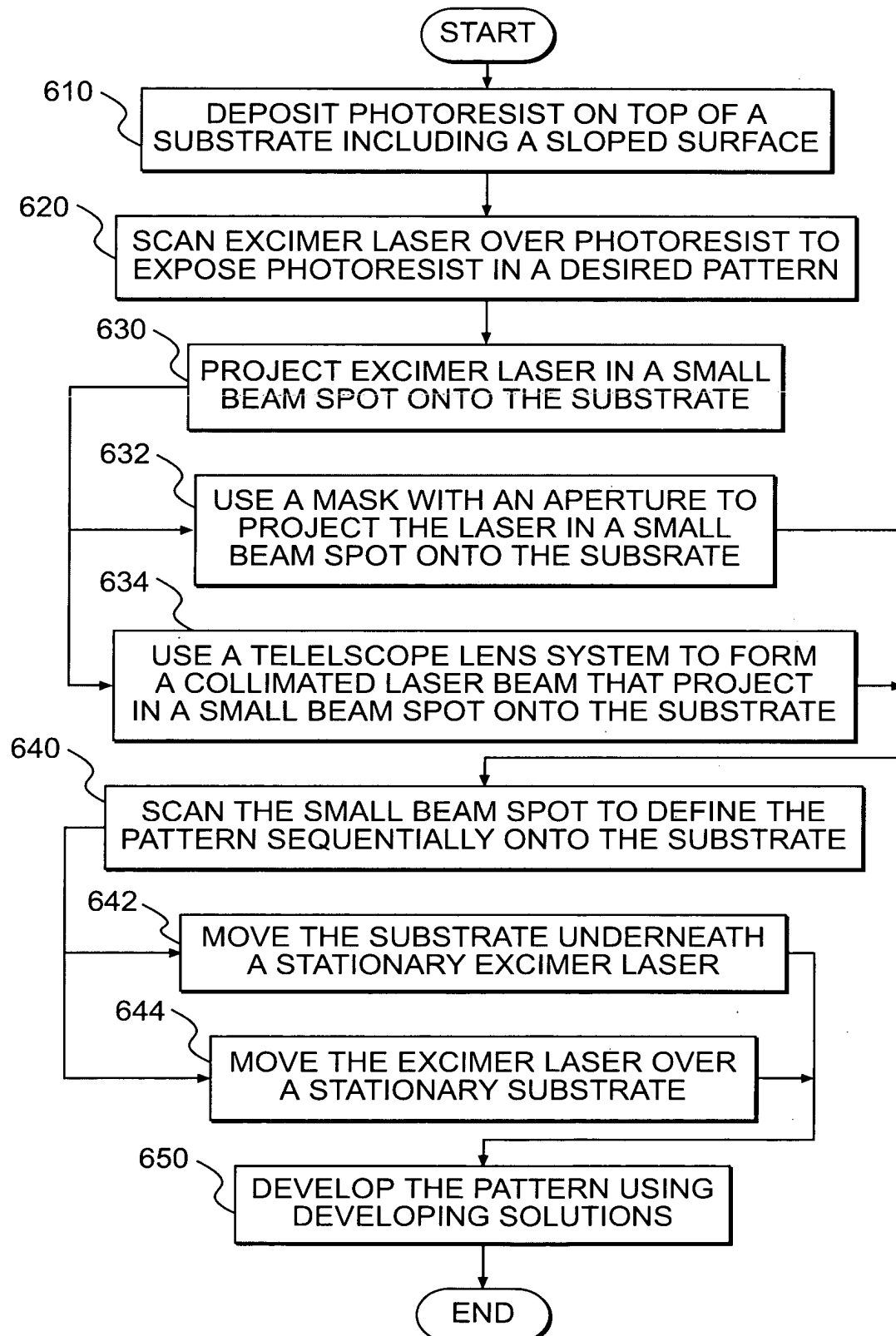


FIG. 5



**FIG. 6**